

Arylene Silicon Compounds

H. N. BECK and R. G. CHAFFEE

Research Laboratories, Dow Corning Corporation, Midland, Mich.

The *in situ* Grignard reaction between arylene halides and diorganomonochlorosilanes has yielded arylene silicon compounds, $\text{HR}_b\text{R}_c\text{SiZSiR}_c\text{R}_b\text{H}$, in which R_b and R_c are methyl and phenyl and Z is *p*-phenylene, α,α' -*p*-xylylene, 4,4'-diphenylene, 4,4'-diphenyleneoxy, bis-4,4'-(methylenephenylene)oxy, durylene, and 1,4-naphthylene. Careful hydrolysis of the bis-silanes yielded the corresponding silarylene diols.

WE WISH to report the preparation of new arylene silicon compounds by the *in situ* Grignard technique (1-6), Equation (1).

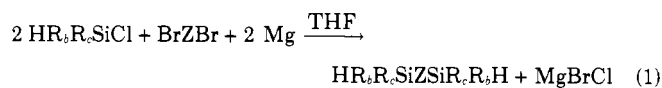


Table I lists the bis-silanes prepared and their physical properties, compounds I-XII. Compounds V and VIII were not isolated in pure state and remained after stripping to the indicated temperatures and pressures. Compounds VII and VIII were prepared from 4,4'-bis(chloromethylphenyl)ether; all others from the corresponding dibromo compounds. A reaction employing dimethylchlorosilane and 9,10-dibromoanthracene yielded a very complex mixture. Distillation gave a poor yield of an impure, viscous, yellow-green fluorescent liquid, b.p. 245 to 285° C. at 0.9 mm. of Hg, whose infrared spectrum was consistent with 9,10-bis(dimethylsilyl)anthracene. Calculated for $\text{Si}_2\text{C}_{18}\text{H}_{22}$: % C, 73.4; % H, 7.5 Found: % C, 74.8; % H, 8.4.

In many cases the corresponding silarylene diols, $\text{HOR}_b\text{R}_c\text{SiZSiR}_c\text{R}_b\text{OH}$, were isolated by carefully hydrolyzing the bis-silanes according to the procedure of Merker and Scott (4), Table I, compounds XIII-XXI. Compound XV was prepared from crude V, but the other diols were from purified silanes. Melting point determinations were initiated at room temperature. Condensation to siloxane most likely occurred during prolonged heating and contributed to the melting point ranges in some cases. Silanol analyses by the Grignard method were consistently low, possibly due to base-catalyzed condensation to siloxane and water. However, theoretical water was obtained from the polymerization of each diol to high polymer in benzene using tetramethylguanidine 2-ethylhexoate catalyst (4). The infrared spectra were consistent with the proposed structures and showed the compounds to be free of siloxane except for a trace in XVII and XXI. The attempted preparation of *p*-bis(phenylmethylhydroxysilyl)benzene from *p*-bis(phenylmethylsilyl)benzene, II, always gave polysiloxane instead of diol.

Preparation of Bis-silanes (I-XII). A solution of the dihalide (1 mole) in a minimum amount of tetrahydrofuran was added to a stirred mixture of magnesium turnings (2.5 gram-atoms), diorganochlorosilane (2.25 moles), and tetrahydrofuran (250ml.) at a rate sufficient to maintain gentle reflux. Extremely insoluble dihalides such as 4,4'-dibromobiphenyl and 1,4-dibromodurene were added slowly as slurries in tetrahydrofuran. Upon completion of addition the mixture was stirred and heated at gently reflux overnight. The mixture was then cooled and filtered. The residue was extracted by slurring with *n*-hexane and filtered. The combined filtrate and extracts were washed free of magnesium salts with water and dried over sodium sulfate. After removal of solvent, the crude product was purified either by recrystallization or by reduced pressure distillation through a six-inch unpacked column.

Preparation of Diols (XIII-XXI). The bis-silane (1 mole) was added dropwise during a fifteen minute to one hour period to refluxing ethanol containing a small piece of sodium metal. Upon completion of addition the mixture was maintained at gentle reflux for several hours until hydrogen evolution ceased. The cooled mixture was added slowly to a stirred solution of sodium hydroxide (5 moles) in 700ml. methanol and 80ml. water. A solution of sodium hydroxide (5 moles) in 780ml. water was added to this solution during a period of 10 to 20 minutes. The resultant solution was allowed to stand one hour at room temperature. The sodium salt was hydrolyzed by dropwise addition of this solution during a 1½ to 2 hour period to a rapidly stirred solution of potassium diacid phosphate (7.6 moles) in excess ice water. The use of phosphoric acid instead of KH_2PO_4 gave nearly identical yields of diol; ammonium carbonate failed to give consistently good yields. The crude white diol was filtered, dried, and recrystallized from either benzene or *n*-hexane.

ACKNOWLEDGMENT

We wish to thank Mr. David E. Sias and Mr. Walter W. Wiechmann for their help in the synthesis of many of these compounds and Dr. E.P. Plueddemann for a sample of dibromodurene.

Table I. Arylene Silicon Compounds, R_aR_bR_cSiZSiR_cR_bR_a

No.	R _a	R _b	R _c	Z
I	H	e	e	-p-C ₆ H ₄ -
II	H	Ph	Me	-p-C ₆ H ₄ -
III	H	Ph	Ph	-p-C ₆ H ₄ -
IV	H	Me	Me	-4,4'-C ₆ H ₄ C ₆ H ₄ -
V	H	Ph	Ph	-4,4'-C ₆ H ₄ C ₆ H ₄ -
VI	H	Me	Me	-4,4'-C ₆ H ₄ OC ₆ H ₄ -
VII	H	Me	Me	-4,4'-CH ₂ C ₆ H ₄ OC ₆ H ₄ CH ₂ -
VIII	H	Ph	Ph	-4,4'-CH ₂ C ₆ H ₄ OC ₆ H ₄ CH ₂ -
IX	H	Me	Me	-4,4'-CH ₂ C ₆ H ₄ CH ₂ -
X	H	Me	Me	-1,4-C ₁₀ H ₆ -
XI	H	Me	Me	-[2,3,5,6-(CH ₃) ₄ C ₆]-
XII	H	Me	Me	-m-C ₆ H ₄ -
XIII	HO	Ph	Ph	-p-C ₆ H ₄ -
XIV	HO	Me	Me	-4,4'-C ₆ H ₄ C ₆ H ₄ -
XV	HO	Ph	Ph	-4,4'-C ₆ H ₄ C ₆ H ₄ -
XVI	HO	Me	Me	-4,4'-C ₆ H ₄ OC ₆ H ₄ -
XVII	HO	Me	Me	-4,4'-CH ₂ C ₆ H ₄ OC ₆ H ₄ CH ₂ -
XVIII	HO	Me	Me	-4,4'-CH ₂ C ₆ H ₄ CH ₂ -
XIX	HO	Me	Me	-1,4-C ₁₀ H ₆ -
XX	HO	Me	Me	-[2,3,5,6-(CH ₃) ₄ C ₆]-
XXI	HO	Me	Me	-m-C ₆ H ₄ -

	%, Yield ^a	Boiling Point ^b		n _D ²⁵	d ₄ ²⁵	R _D		%, Si	
		° C.	Mm. of Hg			Found	Calcd. ^c	Found ^d	Calcd.
I	53	178	22	1.5445	0.9974	0.3232	0.3318	21.8	21.9
II	46.5	188	1.4	1.5892	1.027	0.3282	0.3296	17.5	17.6
III	47	107-108 ^g	12.6	12.7
IV	36	140-141 ^h	0.85	1.5742	0.9663	0.3413	0.3354	20.3	20.8
V	~80	10.6	10.8
VI	68	135 ⁱ	0.45	1.5478	0.976	0.3255	0.3181	19.5	19.6
VII	93	155	0.6	1.5429	0.971	0.3245	0.3186	17.9	17.9
VIII	41	9.78	9.98
IX	49	81 ^k	0.8	1.5002	0.8703	0.3381	0.3340	25.0	25.2
X	74	110-112	0.45	1.5765	0.973	0.3403	0.3355	23.2	23.0
XI	43	106-109 ^l	21.8	22.4
XII	48	58-59	1.1	1.4974	0.8703	0.3365	0.3355	28.5 ^m	28.9
XIII	73	226-228 ⁿ	11.4	11.8
XIV	77	176-180 ^o	17.8	18.6
XV	23	191-193 ^p	10.3	10.2
XVI	74	96 ^q	16.4	17.6
XVII	45	84-88 ^r	16.3	16.2
XVIII	44	121-122 ^{s,p}	22.1	22.1
XIX	29	183-188 ^t	18.9	20.3
XX	38	146-150 ^u	18.7	19.9
XXI	67	81.5-83.0 ^v	24.9 ^w	24.8

^aBis-silane yield based on dihalide; yield of diol based on bis-silane. ^bUncorrected. ^cBased on values of A. I. Vogel, *et al.*, *J. Chem. Soc.* 531 (1952); *J. Phys. Chem.* 58, 174 (1954). ^dAnalyses by Analytical Laboratories, Research Department, Dow Corning Corp. ^ep-HPhMeSiC₆H₄SiMe₂H from equimolar amounts of HPhMeSiCl and HMe₂SiCl. ^fMelting point, uncorrected, on Fisher-Johns apparatus. ^gFrom acetone. ^hGreen solid, distilled to maximum T_{head} 256° C. at 0.63 mm. of Hg and T_{pot} 294° C. ⁱD.R. Weyenberg, unpublished data, b.p. 120° C. at 0.7 mm. of Hg,

n_D²⁵ 1.5478, 41%. ^jBrown gum, distilled to maximum T_{head} 250° C. at 1.5 mm. of Hg and T_{pot} 310° C. ^kR.L. Merker and M.J. Scott, unpublished data, b.p. 132° C. at 20 mm. of Hg, n_D²⁵ 1.5012, d₄²⁵ 0.878, 73%. ^lFrom chloroform. ^m% C, found 61.7, calcd. 61.8; % H, found 9.6, calcd. 9.3. ⁿReported (5), 170-180° with decomposition, 90%. ^oReported (5), 85-96.5° with decomposition, 90%. ^pR.L. Merker and M.J. Scott, unpublished data, m.p. 118.5-119°, 65%. ^q% C, found 52.8, calcd. 53.0% H, found 8.1, calcd. 8.0.

LITERATURE CITED

- (1) Breed, L.W., Haggerty, W.J. Jr., Baiocchi, F., *J. Org. Chem.* 25, 1633 (1960).
- (2) Chaffee, R.G., Beck, H.N., *J. Chem. Eng. Data*, 8, 453 (1963).
- (3) Gainer, G.C., U. S. Patent 2,709,692 (May 31, 1955); *Chem. Abstr.* 49, 12875 (1955).
- (4) Merker, R.L., Scott, M.J., *J. Polymer Sci.* (In press).
- (5) Omietanski, G.M., Reid, W.G., Proceedings 6th J.A.N.A.F. Conference on Elastomers R and D, October 18-20, 1960, Vol. 2, Boston, pp. 603-611. No experimental conditions are presented.
- (6) Sveda, M., U. S. Patent 2,561,429 (July 24, 1951); *Chem. Abstr.* 46, 1814 (1952).

RECEIVED for review April 8, 1963. Accepted May 27, 1963.